# Bulk and surface electronic structure of  $1T \cdot T$ iS<sub>2</sub> and  $1T \cdot T$ iS $e_2$

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*Ab initio* band-structure calculations were performed for bulk, single slab, and thin films of TiX<sub>2</sub>  $(X = S, Se)$ using the localized spherical wave method. According to these calculations, bulk  $TiS<sub>2</sub>$  and  $TiS<sub>2</sub>$  are semimetallic. The calculations show that TiS<sub>2</sub> thin films are semiconductors, but thin films of TiSe<sub>2</sub> are semimetallic. The indirect gap for single slab TiS<sub>2</sub> is about 1.0 eV, and the gap becomes smaller with increasing number of layers. When the number of layers increases to 11, the  $TiS<sub>2</sub>$  thin films are semimetallic. All but the surface layers are found to be electrically neutral. The density of states as a function of the energy for the surface layer is different from that of the bulk. The Madelung energy of the Ti atoms on the surface is about 0.35 eV lower than that for the Ti atoms in the bulk. The calculations are compared with photoemission spectra, reported in the literature. [S0163-1829(97)05532-X]

## **I. INTRODUCTION**

This paper addresses three interesting problems concerning the electronic structure of  $TiS_2$  and  $TiSe_2$ . In the first place, we discuss the problem of whether  $TiS_2$  and  $TiSe_2$  are semimetals or semiconductors. Second, we investigate the difference between the electronic structure of the  $(001)$  surface layer of a  $TiS_2$  crystal and the bulk. We show that the difference is quite large, and that it has important implications for the interpretation of photoelectron spectra of  $TiS<sub>2</sub>$ and TiSe $_2$ . Finally, we study the effects of quantum confinement of electrons in a thin slab of  $TiS<sub>2</sub>$ , and find that a simple slab of  $TiS<sub>2</sub>$  is a semiconductor with a band gap of about 1.0 eV.

 $TiS<sub>2</sub>$  and  $TiSe<sub>2</sub>$  crystallize in a simple layer-type structure of the  $Cd(OH)_2$ -type. The structure consists of sandwich slabs, each slab with two layers of  $S(Se)$  atoms, and with Ti atoms in octahedral holes. The bonding between the slabs is very weak, and is determined by van der Waals forces. This is the reason for the large stability of the  $|001|$  surface of the slabs. Low-energy electron diffraction and scanning tunneling microscopy studies showed no surface reconstruction.<sup>1</sup> At temperatures below 220 K TiSe<sub>2</sub> shows a charge-density wave distortion, leading to a  $2a \times 2a \times 2c$  superstructure.<sup>2</sup>  $1T$ -TiS<sub>2</sub> shows no distortion. In this paper we will refer to a ''layer'' or a ''sandwich'' as an entity comprising a S-Ti-S trilayer, and the phrase ''atomic layer'' for the one-atomlayer case.

The layered compounds  $TiS_2$  and  $TiSe_2$  have been intensively investigated for more than three decades, not only because of their technological use in high-energy-density batteries, but also because of their interesting electronic structure.<sup>2,3</sup> The question of whether they are intrinsically semiconducting or semimetallic has presented a challenge to both experimental and theoretical techniques. The early optical experiments on  $TiS<sub>2</sub>$  and  $TiSe<sub>2</sub>$  suggested that both compounds were semiconductors with band gaps of  $1-2$  $eV<sup>4</sup>$ , the metallic properties of each being attributed to impurities and defects. Takeuchi and Katsuta<sup>5</sup> proposed that the metallic properties are intrinsic, resulting from an overlap of the chalcogen  $p$  and titanium  $d$  bands. For  $TiS<sub>2</sub>$  this view was apparently supported by extensive resistivity experiments on pure samples, which revealed a  $T^2$  dependence over a range of  $10-400$  K,<sup>6</sup> by studies of the variation of the resistivity, thermopower, and lattice parameters with stoichiometry,<sup> $\prime$ </sup> and by angle-integrated photoemission experiments which show a long tail in the density of states indicating band overlap or a band gap of not more than 0.1  $eV^{8,9}$  Infrared reflectance spectra show that TiS<sub>2</sub> is a semimetal and has free carriers in excess of  $10^{22}/\text{cm}^3$ . <sup>10,11</sup> Most of the angle-resolved photoemission experiments reported overlapping hands in TiSe<sub>2</sub>.<sup>1,12-19</sup> In one publication<sup>20</sup> the apparent absence of Se 4*p* holes in the valence band was taken as evidence that  $TiSe<sub>2</sub>$  is a semiconductor, with a band gap of 0.06 eV. Angle-resolved photoemission of  $TiS<sub>2</sub>$ showed the presence of electrons in the Ti 3*d* band, consistent with the observed *n*-type conductivity.<sup>12–15,21–24</sup> These experimental data did not reveal the presence of holes in the S  $3p$  valence band of TiS<sub>2</sub>. This was taken as evidence for the semiconducting character of  $TiS<sub>2</sub>$ , and from the data an energy gap of  $0.3\pm0.2$  eV was deduced. In this interpretation, the conduction electrons in the Ti 3*d* band must be due to point defects, i.e., to excess Ti atoms.<sup>25</sup> A problem with this interpretation is that it is not compatible with experimental data for the stoichiometry; the sample was reported to be stoichiometric within 0.5%, but the number of conduction electrons is much larger than corresponds with this number.<sup>15</sup>

In order to clarify the experimental and theoretical pictures for the electronic structure of these compounds, many band-structure calculations have been done. The early nonself-consistent calculations gave gaps that were far too large: 2.0 eV for TiS<sub>2</sub>, 3.5 eV for TiSe<sub>2</sub>;<sup>26</sup> 1.4 eV for TiS<sub>2</sub>, 0.5 eV for TiSe<sub>2</sub>.<sup>27</sup> The later self-consistent calculations have come close to experiment: a  $0.23$ -eV gap for TiS<sub>2</sub>,  $0.18$ -eV overlap for TiSe<sub>2</sub>,<sup>28,29</sup> 0.5-eV overlap for TiS<sub>2</sub>;<sup>30</sup> 0.24-eV overlap for TiS<sub>2</sub>, 0.55-eV overlap for TiSe<sub>2</sub>;<sup>31</sup> 0.007-eV overlap for  $TiS_2$ .<sup>32</sup> All these calculations are related to the bulk structure and could not fully explain the experimental data on photoemission and transport properties.

(a) 1*T*-TiS<sub>2</sub>:  $a = 3.407$  Å,  $c = 5.6953$  Å Atom WP Coordinates  $R_{\text{WS}}(\text{\AA})$  Electronic configuration Ti 1*a* 0.0, 0.0, 0.0 1.2067 [Ar]  $4s^{0.16}4p^{0.222}3d^{1.86}4f^{0.03}$ S 2*d*  $\frac{1}{3}$  $\frac{1}{3}$ ,  $\frac{2}{3}$ , 0.2501 1.7209  $[Ne] 3s^{1.92}3p^{4.47}3d^{0.30}$ Va  $1b$  0.0, 0.0,  $\frac{1}{2}$ 1.2067 1*s*<sup>0.12</sup>2*p*<sup>0.15</sup>3*d*<sup>0.08</sup> (b) 1*T*-TiSe<sub>2</sub>:  $a = 3.540$  Å,  $c = 6.008$  Å Atom WP Coordinates  $R_{WS}$  (A) Electronic configuration Ti 1*a* 0.0, 0.0, 0.0 1.302  $[Ar] 4s^{0.23}4p^{0.30}3d^{2.07}4f^{0.03}$ Se  $2d$   $\frac{1}{3}$  $\frac{1}{3}$ ,  $\frac{2}{3}$ , 0.2550 1.784 [Ne]  $4s^{1.92}4p^{4.27}4d^{0.24}4f^{0.07}$ Va  $1b$ ,  $0.0, 0.0, \frac{1}{2}$ 1.261  $1s^{0.13}2p^{0.17}3d^{0.09}$ 

TABLE I. Input parameters [lattice parameters, coordinates, empty spheres (Va), and Wigner-Seitz radii  $R_{\text{WS}}$ ] and final electronic configurations. WP represents the Wyckoff position.

This paper presents band-structure calculations using an *ab initio* method for bulk, single slab, and thin films of  $1T-TiX_2$  ( $X=S$ , Se). We find that bulk TiS<sub>2</sub> is, as TiSe<sub>2</sub>, an intrinsic semimetal. Thin films of  $TiS<sub>2</sub>$  are intrinsic semiconductors while thin films of  $TiSe_2$  remain semimetallic.

#### **II. BAND-STRUCTURE CALCULATIONS**

#### **A. Crystal structure**

1*T*-Ti $X_2$  (*X*=S, Se, Te) crystallizes in the 1*T*-type 1*T*-TiX<sub>2</sub> (*X* = S, Se, Te) crystallizes in the 1*T*-type Cd(OH)<sub>2</sub> structure (space group  $P\overline{3}m1$ ). One Ti atom is at  $1a$  (origin) and two *X* atoms at  $2d$  ( $1/3,2/3,z$ ) and  $(2/3,1/3,-z)$ , with  $z=0.2501(4)$  for TiS<sub>2</sub> and *z*  $= 0.255 04(3)$  for TiSe<sub>2</sub>.<sup>33,34</sup> The structure consists of *X*-Ti-*X* sandwiches, separated in the **z** direction by the socalled van der Waals gap. The Ti atoms are trigonalantiprismatically coordinated by *X* atoms. There is one sandwich per unit cell.

#### **B. Details of the calculations**

*Ab initio* band-structure calculations were performed with the localized spherical wave  $(LSW)$  method<sup>35</sup> using a scalarrelativistic Hamiltonian. We used local-density exchangecorrelation potentials<sup>36</sup> inside space filling, and therefore, overlapping spheres around the atomic constituents. The self-consistent calculations were carried out including all core electrons. Iterations were performed with **k** points distributed uniformly in an irreducible part of the first Brillouin zone  $(BZ)$ , corresponding to a volume of the  $BZ$  per  $k$  point of the order of  $1 \times 10^{-5}$   $\rm \AA^{-3}$ . Self-consistency was assumed when the changes in the local partial charges in each atomic sphere decreased to the order of  $10^{-5}$ .

In the construction of the LSW basis,  $35,37$  the spherical waves were augmented by solutions of the scalar-relativistic radial equations indicated by the atomic symbols 3*s*,3*p*,3*d*, 4*s*,4*p*,3*d*, and 4*s*,4*p*,4*d* for S, Ti, and Se, respectively. The internal *l* summation used to augment a Hankel function at surrounding atoms was extended to  $l=3$ , resulting in the use of 4*f* orbitals for Ti and Se. When the crystal is not very densely packed, as in the case in the layered structure of the  $TiX<sub>2</sub>$ , and in particular in the case of thin films, it is necessary to include empty spheres in the calculations. The functions 1*s* and 2*p*, and 3*d* as an extension, were used for the empty spheres.

The input for the band-structure calculations of  $1T$ -TiS<sub>2</sub> and  $17$ -TiSe<sub>2</sub> is listed in Table I. For the TiX<sub>2</sub> multiple layers, the thin films were constructed by  $m+n$  layers with *m* being the number of sandwiches  $\text{Ti}X_2$  and *n* the number of "sandwiches" of the empty spheres  $[n]$  is not less than 3 (about 17 Å)]. The height of one sandwich of the empty spheres was the same as one  $TX_2$  sandwich. All thin films spheres was the same as one  $TX_2$  sandwich. All thin films<br>have space-group  $P\overline{3}m1$  (no. 164), the same Wigner-Seitz radii, and the same radii-overlap for the same compound. The Wigner-Seitz radii and empty spheres were determined by the requirement that the pressure 3 *P*V and the individual contribution to it are minimal. This procedure proves to lead to accurate results as was shown in a comparison with a full-potential method.<sup>38</sup>

## **C.** Bulk  $1T - TiX_2$   $(X = S, Se)$

The input parameters and calculated electronic configurations are listed in Table I(a) for  $1T$ -TiS<sub>2</sub> and Table I(b) for  $1T$ -TiSe<sub>2</sub>. Figure 1 shows the first BZ and the high-17-TiSe<sub>2</sub>. Figure 1 shows the first BZ and the high-symmetry points for the structure with space-group  $P\overline{3}m1$ . Figures  $2-5$  show the density of states  $(DOS)$  and the dispersion of the energy bands. The energies of the states at  $\Gamma$ are given in Table II.

The calculated hand structures of  $1T$ -TiS<sub>2</sub> and  $1T$ -TiSe<sub>2</sub> are similar to previous self-consistent calculations. $28-32$  For  $1T$ -TiS<sub>2</sub> the two lowest bands are mainly composed of S 3s states (Figs. 2 and 3). The energy of these two bands is between  $-13.5$  to  $-11.5$  eV. Between  $-5.3$  eV and  $+0.4$ 



FIG. 1. Brillouin zone and high-symmetry points for  $1T$ -Ti $X_2$ .



FIG. 2. Total and partial density of states for  $1T$ -TiS<sub>2</sub>.

eV above the Fermi level  $E_F$  there are six bands of S 3*p* orbitals. The top and bottom of this set of bands are situated in  $\Gamma$ . Five Ti 3*d* bands of which the crystal-field splitting of an octahedrally coordinated Ti atom (three lower-lying nonbonding  $t_{2g}$  and two antibonding  $e_g$  states) can be recognized, are above the Fermi level.

It is pointed out that the dispersion of two of the bands in the  $\mathbf{k}_z$  direction  $\Gamma$ -*A* is quite large. These are bands of mainly S  $3p<sub>z</sub>$  character. The overlap between the S  $3p<sub>z</sub>$  orbitals within a slab, and also the overlap between S  $3p<sub>z</sub>$ across the van der Waals gap is quite large, leading to a total band width of about 5 eV. Nevertheless, there is no net bonding across van der Waals gap because both bonding and antibonding states are occupied. (It is worthwhile to note that interactions should not be confused with bonding which is the sum of all interactions.) An indirect overlap of about 0.7 eV exists between the top of the S  $3p$  valence band in  $\Gamma$  and the bottom of the Ti 3*d* conduction band situated in *L*, which agrees with some of the calculations in the literature. $30,31$ 

We describe briefly, the nature of the wave functions of the S  $3p<sub>z</sub>$  band, because this will be relevant for the discussion of the electronic structure of the thin films. We use the symmetry labels as given by Miller and Love.<sup>39</sup> The upper S  $3p_z$  band  $(\Gamma_2^-$ - $A_2^+$  in Fig. 6) corresponds to states with wave functions which are antibonding within a slab. The maximum of the band  $(\Gamma_2)$  is antibonding across the van der



FIG. 3. Dispersion of the energy bands of  $1T$ -TiS<sub>2</sub>.



FIG. 4. Total and partial density of states for  $1T$ -TiSe<sub>2</sub>.

Waals gap, the minimum  $(A_2)$  is bonding across the van der Waals gap. The lower S  $3p_z$  band  $(\Gamma_1^+$ - $A_1^+)$  is bonding within the sandwich, and bonding  $(\Gamma^+)$  and antibonding  $(A_1^+)$  across the van der Waals gap, respectively. The nature of the wave functions is illustrated in Fig. 7.

The band structure of TiSe<sub>2</sub> is similar to that of TiS<sub>2</sub>. The two Se  $4s$  bands are between  $-13.8$  to  $-12.0$  eV. The six Se  $4p$  bands are from  $-5.2$  to 0.6 eV above the Fermi level. The bottom and top of the S  $3p$  bands are at  $\Gamma$ . The five Ti 3*d* bands are easily recognized. The bottom of the conduction band is at L. There is an overlap of about 0.8 eV at  $\Gamma$ and *L*.

Near the maximum of the valence band at  $\Gamma$  there are three energy bands with symmetry  $\Gamma_2^-$ ,  $\Gamma_3^-$ , and  $\Gamma_3^+$ . A point of controversy in the literature is the topology of these bands, i.e., the ordering of the states  $\Gamma_3^+$ ,  $\Gamma_2^-$ , and  $\Gamma_3^-$ . An ordering  $E(\Gamma_3^+) > E(\Gamma_3^-) > E(\Gamma_2^-)$  was reported for TiS<sub>2</sub> (Refs. 30 and 31) and TiSe<sub>2</sub>.<sup>16,29</sup> An ordering  $E(\Gamma_3^+)$  $>E(\Gamma_2^-)$  *E*( $\Gamma_3^-$ ) was reported for TiS<sub>2</sub>,<sup>28</sup> and  $E(\Gamma_3^-)$  $\geq E(\Gamma_3^{\frac{1}{2}}) \geq E(\Gamma_2^{\frac{1}{2}})$  for TiSe<sub>2</sub>.<sup>31</sup> In our calculations we found an ordering  $E(\Gamma_3^-) > E(\Gamma_3^+) > E(\Gamma_2^-)$  for TiS<sub>2</sub>, and  $E(\Gamma_3^-)$  $>E(\Gamma_2^-)$  $E(\Gamma_3^+)$  for TiSe<sub>2</sub>. The effects of spin-orbital interaction have been neglected in all calculations. In our opinion, the accuracy of the calculations is not sufficient to establish with certainty the order of the states  $\Gamma_3^-$ ,  $\Gamma_2^-$ ,  $\Gamma_3^+$ and the (positive or negative) value of the small energy gap between valence and conduction bands.

The Fermi surfaces of  $TiS_2$  and  $TiSe_2$  obtained from our calculations are similar. They are composed of an ellipsoid



FIG. 5. Dispersion of the energy bands of  $1T$ -TiSe<sub>2</sub>.

	$1T$ -TiS <sub>2</sub>			$1T$ -TiSe <sub>2</sub>	
Energy $(eV)$	Symmetry	OC	Energy $(eV)$	Symmetry	OC
$-13.38$	$1+$	S <sub>3s</sub>	$-13.83$	$1+$	Se $4s$
$-11.92$	$2 -$	S <sub>3s</sub>	$-12.50$	$2 -$	Se $4s$
$-5.23$	$1+$	$S3p_z$	$-5.16$	$1+$	Se $4p_z$
$-2.38$	$3+$	S $3p_x$ , $3p_y$	$-2.10$	$3+$	Se $4p_x$ , $4p_y$
0.13	$2 -$	$S_3p_z$	0.30	$3+$	Ti $3d^*$
0.41	$3+$	Ti $3d^*$	0.32	$2 -$	Se $4p_z$
0.42	$3-$	S $3p_x$ , $3p_y$	0.38	$1+$	Ti $3d_{72}$
0.76	$1+$	Ti $3d_{72}$	0.61	$3-$	Se $4p_x$ , $4p_y$
3.65	$3+$	Ti $3d^*$	3.06	$3+$	Ti $3d^*$

TABLE II. Energy, dominant orbital character (OC) and symmetry [according to Miller and Love, (Ref. 39)] of the states at  $\Gamma$  for bulk 1*T*-TiS<sub>2</sub> and 1*T*-TiSe<sub>2</sub>. Ti 3*d*\* indicates a mix of Ti 3*d<sub>x<sup>2</sup>-y*2</sub>, 3*d<sub>xy</sub>*, 3*d<sub>xz</sub>*, and 3*d<sub>yz</sub>* orbitals.

around  $\Gamma$ , two cylinders along  $\Gamma$ -*A*, and one bowl around *L*. The ellipsoid consists of S  $3p<sub>z</sub>$  (Se  $4p<sub>z</sub>$  for TiSe<sub>2</sub>) states, the two cylinders of S  $3p_x$  and S  $3p_y$  (or Se  $4p_x 4p_y$  for TiSe<sub>2</sub>) states, while the bowl consists of Ti  $3d$  states. There are more electron-occupied Ti  $3d$  states for TiSe<sub>2</sub> than for  $TiS<sub>2</sub>$ .

In band-structure calculations it is frequently found that the energy gap depends on the Wigner-Seitz (WS) radii and the empty spheres. In the calculations of  $1T$ -TiS<sub>2</sub>, we carried out calculations with different WS radii and with or without empty spheres. It was found that when the number of **k** points is less than 200 the energy gaps depend on the WS radii and on the presence of the empty spheres. When the number of **k** points is larger than 200, that is, if the volume per **k** point is smaller that  $6 \times 10^{-5}$   $\AA^{-3}$ , the calculated band structure hardly depends on the WS radii of the atoms or on the presence of the empty spheres.

## **D.** Single slab  $\text{Ti}X_2$

The electronic structure was calculated for single layers Ti $X_2$  ( $X = S$ , Se) separated by three sandwiches of empty

 $\overline{2}$ **ENERGY** A Г  $k_{z}$ 

FIG. 6. Dispersion along the  $\bf{k}$ <sub>z</sub> direction of the S 3 $p$ <sub>z</sub> valence bands in bulk  $TiS_2$  and  $TiSe_2$ . The states for a single slab are represented by the two circles on the broken line, the states for a thin film consisting of five slabs by the ten circles.

spheres  $(m=1, n=3)$ . The distance between the slabs is sufficiently large  $(>17 \text{ Å})$ , so that interactions between the slabs are negligible. Since bonding between the layers in the crystal is weak, we do not expect relaxations in the layer at the surface and hence neglect them.

Figures 8 and 9 show the DOS and the dispersion of the energy bands of a single slab of  $TiS<sub>2</sub>$ . The dispersion of the bands and the DOS of a single slab  $TiS<sub>2</sub>$  are similar in many respects with the results obtained for the bulk. This is in agreement with the fact that the main features of the electronic structure are determined by strong covalent intralayer interactions. However, we also observe important differences between single slab and the bulk electronic structure. Whereas, the bulk is semimetallic, with overlapping valence and conduction bands, the single slab is a semiconductor with an indirect energy gap of 1.0 eV. This band gap is not sensitive to the number of *k* points used in the self-consistedfield cycle and ranges from 0.973 eV for 3/*k* points to 0.970 eV for 82 *k* points in the first BZ and beyond. The top of the valence band is at  $\Gamma$ , the bottom of the conduction band is at *L*. This result is in disagreement with calculations by Umrigar *et al.*<sup>30</sup> who uses the augmented plane wave method, and



FIG. 7. Sketch of wave functions for a  $(110)$  section of 1*T*-TiS<sub>2</sub>. Open and solid circles represent S and Ti, respectively. On the sulfur atoms the S  $3p<sub>z</sub>$  orbitals are indicated, the hatched part is a positive sign of the wave-function amplitude, the open part has the negative sign. One of the Ti 3*d eg* orbitals is also drawn. The phases correspond to the wave functions  $\Gamma_1^+$ ,  $\Gamma_2^-$ ,  $A_1^+$ , and  $A_2^-$ .



FIG. 8. Total and partial density of states for single slab  $1T$ -TiS<sub>2</sub>.

found only a small difference between the electronic structures of a single slab and the bulk.

The energy difference between bonding and antibonding S 3s bands at  $\Gamma(A)$  is about 0.9 eV for single slab TiS<sub>2</sub>, considerably smaller than the value 1.5 eV for the bulk at  $\Gamma$ . The larger dispersion in the bulk is caused by overlap between S 3*s* orbitals across the van der Waals gap.

The calculations show that in single slab  $TiS<sub>2</sub>$  there are 0.28 more electrons within the WS sphere of the Ti atoms than for bulk  $TiS<sub>2</sub>$ .

Figures 10 and 11 show the dispersion and DOS of single slab TiSe<sub>2</sub>. The Se 4s states are between  $-13.5$  to  $-12.3$ eV. Se  $4p$  bands are between  $-4.24$  to 0.03 eV above the Fermi level. The top of the Se  $4p$  bands is at  $\Gamma(A)$ . The lowest Se 4*p* bands are at *L*, the same as in the case of single slab  $TiS<sub>2</sub>$ . Five Ti *d* bands form the conduction bands, which are above the Fermi level except at *L*(*M*) where the bands are 0.03 eV below the Fermi level.

There is an important difference between the electronic structures of single slabs of  $TiS<sub>2</sub>$  and  $TiSe<sub>2</sub>$ . Whereas a single slab  $TiS<sub>2</sub>$  is a semiconductor, there is a small overlap of bands in a single slab TiSe<sub>2</sub>, so that single slab TiSe<sub>2</sub> is semimetallic, just as the bulk. By comparing the dispersion curves for bulk and single slab, we observe that the largest differences are for the S  $3p_z$  ( $\Gamma_2^-$ ) states, which is strongly lowered in energy in the single slab.



FIG. 9. Dispersion of the energy bands of single slab  $TiS<sub>2</sub>$ .



FIG. 10. Total and partial density of states for single slab  $TiSe<sub>2</sub>$ .

#### **E. Thin films**

Band-structure calculations were performed for thin films of 5 layers  $(m=5, n=5)$ , 7 layers  $(m=7, n=3)$ , and 11 layers  $(m=11, n=3)$  of TiS<sub>2</sub>.

For the  $TiS<sub>2</sub>$  thin films there are more electrons (about 0.02) within the Wigner-Seitz sphere of the Ti atoms of the outer layer as compared with the inner Ti atoms. Similarly, there are less electrons (about  $0.02$ ) at the S atoms of the outside atomic layer, as compared to the inner S atoms. The individual sandwiches are neutral, except for the surface one, where the uncompensated spilling out of charge into the vacuum leads to a net positive charge of 0.11 electrons.

Figures 12 and 13 $(a)$  show the DOS and the dispersion of the energy bands for a thin film of five layers of  $TiS<sub>2</sub>$ . The calculations show that the five-layer thin film is a semiconductor with a band gap of 0.26 eV.

The ten S  $3s$  bands have an energy between  $-13.8$  to  $-11.9$  eV (compared with  $-13.9$  eV to  $-12.5$  eV in the single layer, and  $-13.5$  eV to  $-11.5$  eV in the bulk). The S  $3p$  bands are in the range from  $-5.6$  eV to  $-0.26$  eV below the Fermi level. The lowest position of the S 3*p* bands for the five-layer structure is almost the same as for bulk  $\text{TiS}_2$ for  $\Gamma$  and *L*. Compared with the electronic structure of single-layer TiS<sub>2</sub> every eigenvalue of the S  $3p<sub>z</sub>$  states at  $\Gamma(A)$  is split into five, due to the number of layers. The splitting is a result of the overlap of S  $3p<sub>z</sub>$  orbitals across the van der Waals gaps in the five-layer thin film. The five levels between  $-0.6$  eV and  $-2.9$  eV correspond to the single state at  $-2.2$  eV for the single slab, and to the upper S  $3p<sub>z</sub>$  band for the bulk  $(\Gamma_2^-$ - $A_2^-$  in Fig. 3). The five levels between -3.7 eV and  $-5.6$  eV correspond to the single state at  $-5.2$  eV



FIG. 11. Dispersion of the energy bands of single slab  $T_i$ Se<sub>2</sub>.



FIG. 12. Total and partial states for a five-layer thin film of  $TiS<sub>2</sub>$ .

for the single slab and to the lower S  $3p<sub>z</sub>$  band for the bulk  $(\Gamma_1^-$ - $A_1^-$  in Fig. 3). Such a splitting can approximately be described by a simple one-dimensional tight-binding method with overlap matrix elements between S  $3p<sub>z</sub>$  orbitals across the van der Waals gap, and corresponds to points on the  $\Gamma$ -*A* dispersion of the bands in the bulk structure (see Fig. 6).

The band structure of five-layer  $TiS_2$  shows an indirect gap of 0.26 eV between  $\Gamma(A)$  and  $L(M)$ , and a direct gap of 0.7 eV at  $\Gamma(A)$ . The conduction band (Ti *d* bands) is above the Fermi level. The 15 low-lying nonbonding  $t_{2g}$  and 10 antibonding  $e_g$  states) are split, as compared with the singlelayer structure. The densities of states of the individual layers are represented in Fig. 12. There are small differences, in particular near the Fermi energy. The energy gap of 0.32 eV for the surface layer is larger than the gap of 0.26 eV for the other layers. However, for the surface layer there is a tail of states from the inner layers whose envelope function is expanded in Bessel functions in the outer layer. A very small contribution in the surface DOS originating from bulk envelope functions remains extending to 0.26 eV. For this reason a DOS for thicker slabs is not included. For the outermost layer we find a much steeper increase with energy of the DOS of the Ti 3*d* states. Thus, the lowest states of Ti 3*d* just above the Fermi energy are composed mainly of orbitals of atoms in the outer layer. On the other hand, the highest states of S 3*p* states just below the Fermi energy have a larger contribution orbitals of atoms in the inner layers.

Figure  $13(b)$  shows the dispersion of the energy bands of 11-layer thin films TiS<sub>2</sub> ( $m \approx 11$ ,  $n \approx 3$ ). In this case, we find a splitting of the S  $3p_z$  states in two series of 11 states at  $\Gamma$ , due to interlayer overlap across the van der Waals gap. For the 11-layer thin film there is a small overlap of bands, so that this film is semimetallic.

The splitting in subbands  $[5 \text{ or } 11 \text{ layers of } T \text{ is } 2 \text{ in } F \text{ is } 3.5$  $13(a)$  and  $13(b)$  is observed throughout the BZ Brillouin zone, but the splitting is generally smaller than it is for the S  $3p<sub>z</sub>$  states at  $\Gamma$ . In particular the lowest valence-band states at *M*(*L*) shows only a very small splitting. This is due to the fact that the wave function of the state is of S  $3p_x$ ,  $3p_y$ 



FIG. 13. Dispersion of the energy bands of a five-layer thin film of TiS<sub>2</sub> (a) and of 11-layer thin film of TiS<sub>2</sub> (the bands above 2.0 eV are not included) (b).

character and does not mix with S  $3p<sub>z</sub>$  states for symmetry reasons. The small splitting at the minimum of the valence band at  $M(L)$  must be due to  $\pi$ -type overlap between S  $3p_x$ ,  $3p_y$  orbitals across the van der Waals gap; this overlap is apparently quite small.

Figure 14 shows the Madelung energy of the atoms along the **z** (interlayer direction) obtained from the band-structure calculation for a film of 11 slabs. The Madelung energy for atom *i* with charge  $Q_i$  within the WS sphere is given by

$$
E_{\text{Mad}}(i) = Q_i \sum_{j \neq i} Q_j / |\mathbf{r}_i - \mathbf{r}_j|;
$$

the summation is over all atoms  $j \neq i$  in the crystal. As shown in Fig. 14, the Madelung energy is almost the same for all the Ti inner atoms, while the Madelung energy is about 0.35 eV lower for the Ti atom of the outer layer. The Madelung energy is almost the same for all inner S atoms. The *E*(Mad) of the next to outermost S atoms is about 0.05 eV lower in energy, as compared with the inner S atoms. However, the outermost S atoms have the Madelung energy as



FIG. 14. The Madelung energy  $(E_{\text{Mad}})$  of the atoms along the *z* direction for half of the 11 sandwiches thin films of  $TiS_2$  (*m*  $=$  11,  $n=3$ ); the first Ti atom is at the origin (center of symmetry) of the unit cell. The sixth Ti is next to the sandwiches of empty spheres.

high as the inner S atoms. These differences in Madelung energy influence the surface electronic structure.

#### **III. DISCUSSION**

From the band-structure calculations we found that bulk  $17$ -TiS<sub>2</sub> and  $17$ -TiSe<sub>2</sub> are semimetals. This result is consistent with electrical transport measurements.

The calculations show that the interlayer interactions of the layered compounds due to overlap between  $S_3 p_7$  orbitals across the van der Waals gap are strong (about  $2-3$  eV), and have an important effect on the electronic structure. The  $\pi$ -type overlap between S 3 $p_x$ , 3 $p_y$  orbitals across the van der Waals gap is much smaller.

Due to the lack of three-dimensional  $(3D)$  translational symmetry, the chemical bonding and electrostatic interactions of the top layer atoms are different from the bulk. This causes important differences between the electronic structures of the surface and the bulk. For  $TiS_2$  the S  $3p/Ti$  3*d* energy gap increases from the bulk to a single slab by about 1.7 eV. This is consistent with the observation that in  $TiS_2$ intercalated with Li, the S 3*p*/Ti 3*d* gap has increased by about 1.0 eV,  $^{16,40}$  because also in this case, the overlap between S  $3p<sub>z</sub>$  orbitals (across the Li layers) is nearly zero. Generally, one finds that intercalation of metal atoms increases the T  $nd/S$  3p gap [e.g., for  $A_xTS_2$  with  $A=Sn$ , Pb; T=Ta, Nb, and for  $ATS_2$  ( $A$ =Fe, Mn;  $T$ =Nb, Ta), by about  $1.0-1.5$  eV]. $^{40,41}$ 

We compare the width  $W_{\pi}$  of the S  $3p_x$ ,  $3p_y$  band ( $\pi$ band) of bulk, single slab, and five-layer TiS<sub>2</sub>. The width  $W_{\pi}$ is obtained from the difference between the highest S  $3p<sub>x</sub>$ ,  $3p_y$  level  $\Gamma_3^-$  and the lowest level at  $M(L)$ , which is of pure S  $3p_x$ ,  $3p_y$  character. The width  $W_\pi$  decreases from 5.46 eV for bulk  $TiS_2$  to values of 5.3 and 4.87 eV for five-layer and a single slab TiS<sub>2</sub>, respectively. For TiSe<sub>2</sub>  $W_{\pi}$  decrease from 5.43 eV for the bulk to 5.17 eV for a single slab. Such a decrease of band width is a general phenomenon due to the decrease of overlap contribution of orbitals of surface atoms.

According to the calculations, there is an appreciable change of the total Ti 3*d* band—width  $W_d$  (which includes the crystal-field splitting) in going from bulk to thin films. The total Ti 3*d* bandwidth  $W_d$  changes from 4.0 eV for bulk  $TiS<sub>2</sub>$  to values of 3.75 eV and 3.25 eV for five-layer and single slab TiS<sub>2</sub>, respectively. For TiSe<sub>2</sub> the values for bulk and surface are 3.73 and 3.33 eV, respectively.

Extensive studies of the photoelectron spectra of  $TiS<sub>2</sub>$  and  $TiSe<sub>2</sub>$  have been reported in the literature, in order to determine the electronic structure and to find out whether  $TiS<sub>2</sub>$ and TiSe<sub>2</sub> are semiconducting or semimetallic.<sup>1,10–19,32</sup> The angle-resolved photoemission data on  $TiS<sub>2</sub>$  are generally in good agreement with the calculated dispersion of the energy bands. The data clearly show the presence of electrons in the Ti 3*d* band near *M*(*L*) point in the BZ Brillouin zone, as predicted by band-structure calculations, and in accordance with the observed *n*-type conductivity. However, the data did not reveal the presence of holes at the top of the valence band near  $\Gamma$ , expected for a semimetal, and predicted by some of the band-structure calculations. Chen *et al.*<sup>15</sup> remarked that the observation that the uppermost S 3*p* band come close to the Fermi energy  $E_F$ , but does not cross  $E_F$ , indicates that TiS<sub>2</sub> is a semiconductor. However, it is difficult to reconcile this conclusion with experimental data on transport properties, which show large conductivity and a number of charge carriers much larger than corresponding to the stoichiometry of the samples. Weitering<sup>19</sup> observed that photoemission spectra of TiS<sub>2</sub>  $(001)$  covered by a thin layer of Ag are very similar to photoemission spectra of a clean  $TiS<sub>2</sub>$  (001) surface. The data indicate that the highest occupied valence state of a  $TiS_2$  or an Ag/TiS<sub>2</sub> surface is about 0.2 eV below the Fermi energy. The Fermi energy is pinned by the Ti 3*d* electrons in the conduction band. Generally, these data are taken as evidence for the semiconducting character of pure  $TiS_2$ , with an energy gap of about 0.2 eV.

We remark that photoemission spectroscopy is a very surface-sensitive technique. The mean free path  $\lambda$  of electrons escaping from the solid is about 10 Å for photoelectrons with an energy about 20 eV. Because the thickness of a single layer  $TiS_2$  is about 6 Å this means that the photoemission signal originates for a fraction  $(l-e^{-\alpha/\lambda})=0.45$  from the outer surface layer, and for a fraction  $e^{-\alpha/\lambda}$  (*l*- $e^{-\alpha/\lambda}$ )  $=0.27$  from the second layer. Therefore the information obtained from photoelectron spectra concerns mostly the electronic structure of the outer layers of the solid.

Pehlke and co-workers $1,18$  have carried out calculations of the photoemission of  $TiS<sub>2</sub>$  and  $TiSe<sub>2</sub>$  using a one-step model for normal electron emission. The calculations show no evidence either for a surface state or a surface resonance. However, it was found that the square-root divergences of the DOS at bulk band-edge disappear for the partial DOS of the surface layer. The calculated photoemission as a function of energy shows important differences if the differences between surface and bulk wave functions are taken into account. The authors stated that this emphasizes the necessity of including surface effects even if there are no surface state or surface resonance.

Our calculations also show the density of states near the Fermi energy of the outer layers of  $TiS<sub>2</sub>$  is quite different from the bulk. For the outer layers the DOS of Ti 3*d* states is enhanced, whereas, the DOS of S 3*p* states near the Fermi energy is lower for the outer layers. Thus, due to this difference in electronic structure between surface and bulk, one expects near the Fermi energy an enhanced photoemission signal for Ti 3*d*, and a decreased signal for S 3*p* states. This explains the discrepancies between the observed photoemission spectra and the semimetallic character of  $TiS<sub>2</sub>$  quite well. The photoelectron spectrum of semimetallic  $TiS_2$  will look like the photoelectron spectrum of a semiconductor because the electronic structure of the surface layer is similar to that of a semiconductor.

TiSe<sub>2</sub> single slab as well as its surface layer is still semimetallic because the effects of broken transitional symmetry are not enough to open an energy gap between Ti 3*d*/S 3*p* states, due to the fact that selenium is less electronegative that sulfur.

We discuss briefly the electronic structure and photoemission of TiTe<sub>2</sub>, which is isomorphous with TiS<sub>2</sub>. Bandstructure calculations show that this material is semimetallic.<sup>42,43</sup> Photoemission data<sup>42,43</sup> are in general agreement with the calculated dispersion of the energy bands, but there are some significant differences. The dispersion of the Ti  $3d_{z^2}$  band appears to be reduced with respect to band theory. The authors $43$  attribute this to Fermi-liquid effects. We like to point out that the change of the partial DOS of the surface layer as compared to the bulk will also lead to an apparent narrowing of the Ti  $3d_{z}$ <sup>2</sup> band. In the angleresolved photoemission spectra the Fermi level crossing of the Te 5*p<sub>z</sub>* band expected for semimetal was not observed. This might be due to a surface effect, as discussed above for  $TiS<sub>2</sub>$ .

The large difference between the electronic structure of bulk and single layer  $TiS_2$  is a nice example of quantum confinement. The S  $3p<sub>z</sub>$  electrons in single layer TiS<sub>2</sub> are confined along the *z* direction perpendicular to the layers. As a result there is no dispersion along the *z* direction. Therefore, the S  $3p<sub>z</sub>$  band, which has a bandwidth and a strong dispersion along  $z$  for the bulk TiS<sub>2</sub>, becomes a narrow band in single-layer  $TiS_2$ . In addition, we observe a significant narrowing of the S  $3p_x$ ,  $3p_y$  band. These effects result in a larger band gap of single layer  $TiS<sub>2</sub>$  versus semimetallic properties of bulk  $TiS<sub>2</sub>$ .

Nanostructured materials have recently attracted intense interest at both fundamental aspects and promising applications. This is due to the observation that important changes occur in the physical properties if electrons are confined to nanometer dimensions.<sup>44</sup> The size quantization in cubic CdS and silicon influences the band gap. In order to obtain a smaller band gap in such cubic nanostructured materials it is necessary that all three dimensions are reduced to nanometer size. For layered materials this is not the case. Due to the large anisotropy of the electronic structure it is possible to have a large change of the band gap if only the thickness of the slab of a layered material is reduced to nanometer size.

## **IV. CONCLUSION**

Calculations of the electronic structure of bulk and thin films of  $TiS_2$  indicate that  $TiS_2$  is a semimetal, but that thin films are semiconducting. It is found that the DOS of the outer layer of a thin film is quite different from the bulk: the outer surface layer has an electronic structure similar to that of a semiconductor with a small energy gap and a very small DOS in the gap (originating from the tails of the states of the inner layers). In the literature, photoelectron spectra were taken as evidence that  $TiS<sub>2</sub>$  is a semiconductor. However, in the discussion of the data, surface effects were not considered. We have shown that the photoelectron spectra are also consistent with semimetallic  $TiS<sub>2</sub>$  if the difference between the electronic structure of the top surface layer and the bulk is taken into account.

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